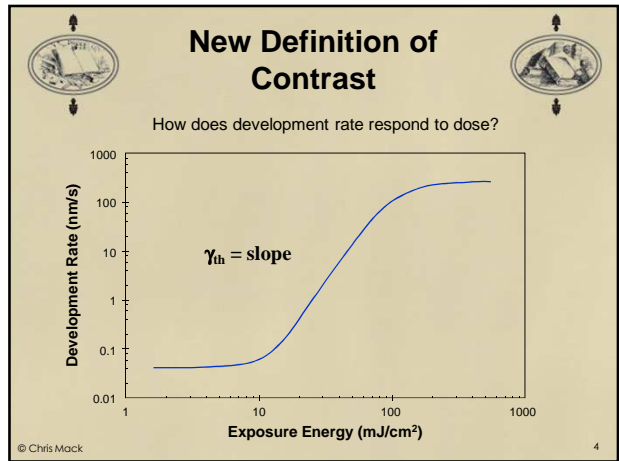
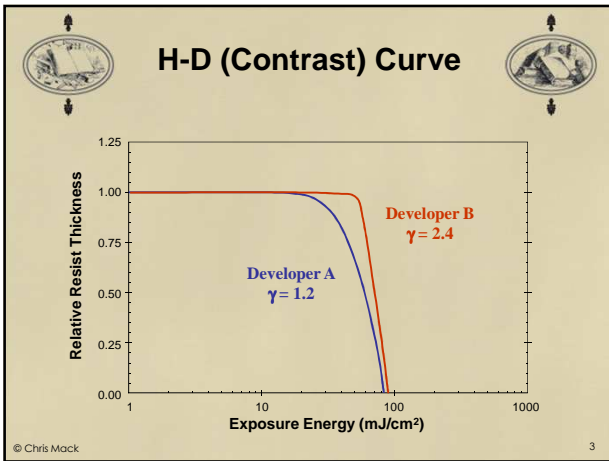
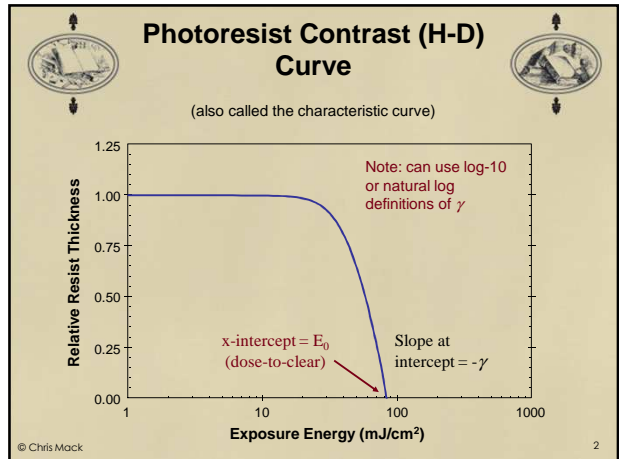


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## Lecture 54 Lithography: Resist Contrast

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### Theoretical Photoresist Contrast

$$\gamma_{th} = \frac{d \ln r}{d \ln E}$$

- Note that theoretical contrast is a function of dose. Often the max value of  $\gamma_{th}$  is used.
- Questions:
  - How does this definition relate to lithographic quality?
  - What is the relationship of theoretical contrast to measured contrast?

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### Photoresist Contrast

$$\frac{d \ln r}{dx} = \gamma_{th} \frac{d \ln I}{dx}$$

- The contrast "amplifies" the image gradient to give a development rate gradient
- This is called the "Lithographic Imaging Equation"

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### Conventional "Definition" of Resist Contrast

$$\gamma_m = \frac{1}{D} \frac{d\tau}{d \ln E} \Big|_{E=E_0}$$

Relative Resist Thickness

Exposure Energy (mJ/cm<sup>2</sup>)

$\tau$  = resist thickness remaining,  $D$  = initial resist thickness

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### Photoresist Contrast: $\gamma_{th}$ VS. $\gamma_m$

Development Rate:  $R = \frac{dz}{dt} \rightarrow \int_0^{t_{dev}} dt = t_{dev} = \int_0^z \frac{dz}{R(z)}$

( $R$  = development rate,  $z$  = depth into the resist)

Now take the derivative with respect to  $\ln(\text{dose})$ :

$$\gamma_m = \frac{R_{bottom}}{D} \int_0^D \gamma_{th} \frac{dz}{R(z)}$$

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### Theoretical Contrast

$$r = r_{max} \frac{(a+1)(1-m)^n}{a+(1-m)^n} + r_{min} \quad a = \frac{n+1}{n-1} (1-m_{th})^n$$

Gamma

Relative Concentration  $m$

$n = 20$   $m_{th} = 0.7$   $n = 10$   $n = 5$

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### Resist Contrast Review

- Theoretical contrast converts the image log-slope into a development rate log-slope
- Measuring resist contrast is tricky using the conventional characteristic curve method – it is almost never worth using
  - Anything that causes the development rate to vary with depth into the resist (e.g., absorption, surface inhibition) causes an error in contrast measurement
- Theoretical contrast can be measured using a development rate monitor

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### Lecture 54: What have we Learned?

- How is the conventionally measured contrast defined?
- How is the theoretical contrast defined?
- When do the conventionally measured and theoretical contrasts give the same result?
- How is contrast related to the dissolution selectivity parameter  $n$ ?

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